

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

## INTERVIEW SUMMARY

Applicant(s): Mahajani et al. Application No.: 10/079472 Filed: 2/19/2002 Title: Gate Dielectric Structures for Integrated Circuits and Methods for Making and Using Such Gate Dielectric Structures Attorney Docket No.: MA-068	Group Art Unit: 2814  Examiner: Thao X. Le
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To the Commissioner:

Examiner Thao X. Le, Supervisor Wael Fahmy, and Agent for Applicants Pamela J. Squyres participated in a telephone interview on April 3, 2003.

All rejected claims were discussed relative to the Luoh et al. reference. US Publication No. 2003/0017670.

Substance of interview: Applicants' representative explained how claim 1 and dependents, and all claims including SONOS limitations, distinguish over Fig. 2 of Luoh et al., and why the 102 and 103 rejections should be withdrawn. Also noted that 103 rejections of March 6 office action do not establish motivation to modify or combine. Possible claim amendments were discussed.

4/30/03  
Date

  
Pamela J. Squyres  
Agent for Applicants  
Reg. No. 52,246

APR 30 2003

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I hereby certify that this paper is being transmitted by facsimile to the U.S. Patent and Trademark Office on the date shown below.

  
Pamela J. Squyres  
Date of Transmission 4/30/03